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# ***UV and Higher Energy Photonics: From Materials to Applications 2019***

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*Editors*

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# Contents

v	<i>Authors</i>
vii	<i>Conference Committee</i>

---

## RAMAN AND ATR SPECTROSCOPY I

---

11086 04	<b>Far- and deep-ultraviolet spectroscopy applied for ionic liquids (Invited Paper) [11086-3]</b>
11086 05	<b>Tunable deep-UV Raman spectroscopy reveals nitrate photolysis [11086-4]</b>

---

## MATERIALS AND DEVICES

---

11086 0C	<b>III-nitride emitters and detectors for UV optoelectronic applications grown by metalorganic chemical vapor deposition (Invited Paper) [11086-41]</b>
----------	---

---

## RAMAN AND ATR SPECTROSCOPY II

---

11086 0N	<b>Frontiers of UV resonant Raman spectroscopy by using synchrotron radiation: the case of aqueous solvation of model peptides (Invited Paper) [11086-21]</b>
11086 0Q	<b>Conformational stability of DNA in hydrated ionic liquid by synchrotron-based UV resonance Raman [11086-24]</b>

---

## DUV MICROSCOPY AND NANOSCOPY

---

11086 0U	<b>UV illumination for electron and ion beam microscopy and nanofabrication [11086-28]</b>
----------	--

---

## DUV PLASMONICS II

---

11086 0X	<b>UV-LED activated semiconductor sensors with tailored structure (Invited Paper) [11086-40]</b>
11086 0Z	<b>Large available volume particles for enhanced deep UV local Raman sensing [11086-32]</b>



## Authors

Numbers in the index correspond to the last two digits of the seven-digit citation identifier (CID) article numbering system used in Proceedings of SPIE. The first five digits reflect the volume number. Base 36 numbering is employed for the last two digits and indicates the order of articles within the volume. Numbers start with 00, 01, 02, 03, 04, 05, 06, 07, 08, 09, 0A, 0B...0Z, followed by 10-1Z, 20-2Z, etc.

Adeli, Babak, 0X  
Bakhtiary-Noodeh, Marzieh, 0C  
Bleiner, D., 05  
Borgschulte, A., 05  
Bottari, Cettina, 0N, 0Q  
Catalini, Sara, 0N  
Chen, Ping, 0C  
Detchprohm, Theeradetch, 0C  
Dupuis, Russell D., 0C  
Espid, Ehsan, 0X  
Fernandez Bravo, Angel, 0Z  
Gessini, Alessandro, 0N, 0Q  
Hallen, Hans D., 0Z  
Jeong, Hoon, 0C  
Ji, Mi-Hee, 0C  
Juodkazis, Saulius, 0U  
Katkus, Tomas, 0U  
Le, Nguyen Hoai An, 0U  
Lim, Shuang Fang, 0Z  
Mancini, I., 0Q  
Masciovecchio, Claudio, 0N, 0Q  
Mehta, Karan, 0C  
Mele, A., 0Q  
Morikawa, Junko, 0U  
Ng, Soon Hock, 0U  
Rossi, Barbara, 0N, 0Q  
Ryu, Meguya, 0U  
Sambalova, O., 05  
Schneider, U., 05  
Schuck, Peter James, 0Z  
Seniutinas, Gediminas, 0U  
Shen, Shyh-Chiang, 0C  
Sterzi, A., 05  
Stoddart, Paul, 0U  
Taghipour, Fariborz, 0X  
Tanabe, Ichiro, 04  
Tsou, Chuan-Wei, 0C  
Wirth, Janina, 0Z  
Yoder, P. Douglas, 0C



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